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TECHNICAL REPORT NO. 1

RAMAN INVESTIGATION OF OPTICAL FIBERS

UNDER HIGH TENSILE STRESS

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"Raman Investigation of Optical Fibers

Under High Tensile Stress"

by

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ABSTRACT

Raman spectra have been obtained from fused silica optical fibers under tensile stresses from 0 to 3.3 GPa (33 kbar). Reversible intensity <u>increases</u>, relative to the principal Raman maximum at 490 cm, ⁻¹ were observed for the defect peak at 490 cm, ⁻¹ and for shoulders near 350-375 cm⁻¹ and 115 cm. ⁻¹ Application of tensile stress to fused silica appears to produce changes in the stretched Si-0 defect sites, as well as changes in the main network structure.

INTRODUCT ION

Raman features from fused silica near 490 and 604 cm⁻¹ have been examined in several recent investigations, (1 - 7)see Fig. 1 (stars). Raman intensities at 490 and 604 cm⁻¹ were found to increase with increasing fictive temperature, $T_{\rm F}$, when the OH content was constant (or zero).⁽⁴⁾ The 490 and 604 cm⁻¹ Raman intensities were also observed to decrease with increasing OH content, at constant $T_{\rm F}$.⁽⁴⁾ In the latter case, a weak Raman band near 970 cm⁻¹ due to Si versus OH stretching,^(4,8) was produced at the expense of intensity at the 490 and 604 cm⁻¹ positions. Other findings, such as the observation that the 490 and 604 cm⁻¹ intensities from samples having high $T_{\rm F}$'s could be reduced by annealing, strengthened the hypothesis that these peaks could be assigned to defects in the silica structure.⁽⁴⁾

The nature of the above defects suggested that their concentration and/or molar intensity should increase under the application of tensile stress. In order to subject a sufficient volume of glass to large tensile stresses, ⁽⁹⁾ experiments were conducted on glass optical fibers. An interpretation of the changes observed in the Raman spectrum is presented in terms of variations in the Si-O binding at defect sites.

EXPERIMENTAL PROCEDURES

Pure fused silica optical fibers were used in all experiments (silicone rubber cladding, 200 μ m diameter).⁽¹⁰⁾ The OH content of the fibers was about 530 ppm,⁽¹¹⁾ and T_F values were estimated to be roughly 1700 - 1800° C.⁽¹²⁾ The constancy of the OH concentration was assured by monitoring the Raman OH-stretching intensity near 3700 cm.⁻¹ (13)

Forward scattered Raman spectra were obtained by focussing the fiber output on the entrance slit of an Instruments S. A. HG2S holographic grating double monochromator, Fig. 2. Raman excitation was accomplished using 514.5 nm argon ion laser radiation at about 0.6 W. Slit-widths ranged from 2 to 3 cm,⁻¹ and detection was accomplished with an uncooled Hamamatsu R928 PM tube, a Keithley 414S picoammeter, and a high-speed Esterline Angus L1101S recorder.

Load was applied to the fiber by suspending a weight from a clamp near the end of the fiber, Fig. 2. The optical fiber was held by strips of sponge rubber placed between wooden strips 30 to 50 cm in length, tightly clamped together in several places. This arrangement prevented any slippage during application of load. The stressed-to-unstressed length ratio was maintained in the range of 5 to 50 to reduce the unstressed spectral contribution.

Some Raman experiments were also attempted in which only stressed fiber was examined by focussing 90 degree scattered radiation on the slit, but these experiments were abandoned because the S/N (signal-to-noise) ratio, although good, was

(4)

at least 20-fold lower than that obtained from forward Raman scattering.

Because the Raman depolarization ratio varies across the fused silica spectrum, (14) it was necessary to determine if the polarization, which is ordinarily scrambled by an optical fiber, changes under tensile stress. Preliminary experiments involved examination of the mode structure and the polarization at the fiber output. No significant changes were observed in the high-order mode structure under stress, and no changes whatever in polarization were detected using polarizers or crossed polarizers.

Quantitative measurements of the polarization were made using the optical fiber emission to excite both forward and 90 degree Raman scattering in liquid CCl_4 . Ratios of integrated Raman intensities were determined for the CCl_4 peaks at 218(dp), 314(dp), and 459(p) cm.⁻¹ (Here dp refers to a depolarization ratio of 0.75 and p to a ratio of about $0.01^{(15)}$.) For both forward and 90 degree scattering, no changes whatever were detected in the intensity ratios I_{459}/I_{314} and I_{459}/I_{218} for tensile stresses to 2.19 GPa. Further, the intensity ratios obtained from CCl_4 were those characteristic of unpolarized excitation, as expected from the fact that polarization is scrambled by internal reflection in high-mode optical fibers. Also, it should be emphasized that the above integrated Raman intensity ratios from CCl_4 constitute a particularly sensitive

(5)

test of the polarization properties of the exciting radiation emitted from the optical fiber.

RESULTS

Stressed and unstressed Raman spectra illustrative of the approximately 50 individual experiments performed are shown in Fig. 1. The (upper) spectrum was taken at a tensile stress of 3.34 GPa (33.4 kbar), while the lower spectrum was taken from an unstressed fiber. The intensification of the 490 cm⁻¹ defect peak (starred), relative to the 440 cm⁻¹ peak, is visually obvious, and is emphasized by the horizontal lines. In the unstressed spectrum, the 490 and 440 cm⁻¹ peaks occur at the same vertical height, as seen by the horizontal line througn them, but at 3.34 GPa (upper) the 490 cm⁻¹ peak height is well above the horizontal line. Similar conclusions may be drawn from examination of the inset of Fig. 1, which refers to three spectra run in the sequence unstressed, U; stressed at 2.19 GPa, S; and, relaxed, R, with 20-30 min between spectra.⁽¹⁶⁾

The visual observation that the 490 cm⁻¹ peak height increases relative to the 440 cm⁻¹ peak height, <u>i.e.</u>, that I_{490}/I_{440} increases, may mean either that I_{490} increased at constant I_{440} , or that I_{440} decreased at constant I_{490} , or that both I_{490} and I_{440} changed, or even that more complicated changes occurred, such as broadening, <u>etc</u>. Hence, if I_{440} is to be regarded as a reference standard, it is desirable to understand how I_{440} varies relative to other peaks, such as the intense peak at 60 cm.⁻¹

(7)

Peak heights above baseline A, Fig. 1, were measured for the 60, 440, and 800 cm⁻¹ peaks at a series of tensile stresses. Consistency of drawing baseline A under all spectra was obtained by using a <u>single</u> template whose shape, baseline A, Fig. 1, was determined through repeated trials. The template was positioned to a given Raman spectrum by simultaneously matching two regions: 1) the region between the exciting line and the sharp minimum near 20 to 25 cm,⁻¹ and, 2) the region from about 900-1000 cm.⁻¹ The results are shown in Table I in terms of the ratios I_{60}/I_{440} , I_{800}/I_{440} , and I_{800}/I_{60} .

The average value for the peak height ratio I_{60}/I_{440} from Table I is 0.70±0.02, which within present errors is constant. Similarly, the ratios I_{800}/I_{440} and I_{800}/I_{60} are also seen to be constant, Table I. The constancy of the ratio I_{60}/I_{440} is particularly important because the peaks at 60 and 440 cm⁻¹ have both the largest peak heights, and the highest integrated intensities (Fig. 1) in the fused silica spectrum.

Quantitative values of peak height ratios are often difficult to obtain accurately when weak features such as at 490 and 604 cm⁻¹ are involved, because such ratios suffer from errors in baseline estimates, and peak S/N ratios. Peak height ratios also ignore component broadening. A better method is to use ratios of integrated intensities. For the 490 and 604 cm⁻¹ peaks, Fig. 1, integrated intensities may be obtained using baseline B. Baseline B was obtained by using a French curve. In contrast,

(8)

an integrated intensity for the 440 cm⁻¹ component could not be readily obtained, because the component shape is unknown. Therefore, the total integrated Raman intensity from about 20 to 900 cm⁻¹ was obtained using baseline A, minus, of course, the contributions from the 490 and 604 cm⁻¹ components. The resulting ratios of integrated Raman intensities, I_{490}/I_T and I_{604}/I_T , where T refers to the total Raman area, minus the 490 and 604 cm^{-1} component areas, are shown for tensile stresses from 0 to 2.19 GPa in Table II. In addition, the quantities I_{400}/I_{440} and I_{604}/I_{440} are listed in the Table, where I_{490} and I_{604} are integrated intensities above baseline B, and I_{440} refers to the peak height above baseline A. The latter ratios were used in Table II because of the intensification of shoulders described subsequently. It should also be made very clear that the 490 cm⁻¹ component area (the integrated component intensity) obtained above baseline B, is independent of effects due to broadening of the 440 cm⁻¹ component. Slight broadening of the 440 cm⁻¹ component was clearly evident from changes in the shape of baseline B under the 490 cm⁻¹ peak, but this broadening effect was completely negated by

It is apparent from Table II, that the only significant changes involve the 490 cm⁻¹ component, as previously suggested from examination of Fig. 1. The original data leading to Table II (using three figures, instead of the two significant figures of the Table) were treated by linear least squares. Changes of about 62% in I_{490}/I_T , and of about 67% in I_{490}/I_{440} , resulted for stresses to 2.19 GPa, using the least squares estimates, but changes in the ratios involving the 604 cm⁻¹ component were not significant (negligible). Because the relative 604 cm⁻¹ intensity did not change with tensile stress, it can be concluded from Tables I and II that

use of baseline B.

(9)

independent of, or vary in the same way with, tensile stress.

In addition to relative intensification of the 490 cm⁻¹ peak, other small spectral changes were seen for Raman features below 440 cm.⁻¹ One effect which occurred consistently throughout this work is an apparent enhancement under tensile stress of a shoulder near 350-375 cm.⁻¹ evident from careful examination of Fig. 1, particularly the inset. In the inset, the region from about 440 cm^{-1} to 350 cm^{-1} has the same slope in both the U and R spectra. However, this slope is smaller for the S spectrum. indicating a slight intensification of the 350-375 cm⁻¹ shoulder component. However, the 350-375 cm⁻¹ shoulder would also appear to intensify, if the 440 cm⁻¹ component broadened. Experience with baseline B at high tensile stress indicates a slight but definite broadening of the 440 cm⁻¹ component. which could account for part (or all) of the intensification at 350-375 cm. In regard to intensification due to broadening of neighboring components, it should be emphasized that the relative intensification at 490 cm⁻¹ cannot be so explained. because the 440 cm⁻¹ broadening is subtracted from the integrated intensity at 490 cm⁻¹ by virtue of curvature in baseline B. Table II.

Some shape changes may also occur in the Raman region between 0 and 200 cm⁻¹ under increasing tensile stress. A shoulder at roughly 115 ± 5 cm⁻¹ appears to be more prominent under high stress, compared to the nominal 60 cm⁻¹ intensity maximum, Fig. 1. The Raman amplitude ratio, I_{115}/I_{60} , using the method A baseline, increases roughly 5% in the figure. The position of the Raman peak at 60 cm⁻¹ seemed not to rise in position significantly, however. For tensile stresses from 0 to 2.19 GPa, the position ranged from 60 ± 2 to 63 ± 2 cm,⁻¹ <u>i.e.</u>, about constant. However, it was not possible to determine whether or not the relative intensification at 115 cm⁻¹ resulted from an increasing half-width of the 60 cm⁻¹ component.

(10)

DISCUSSION

Three distinct types of behavior have now been delineated in regard to the intensity variations of the 490 and 604 cm⁻¹ peaks from fused silica as follows: 1) intensity increases at <u>both</u> the 490 and 604 cm⁻¹ positions with increasing T_F ,⁽⁴⁾ 2) a large intensity increase at 604 cm⁻¹ relative to the 490 cm⁻¹ peak observed when fused silica is densified by neutron irradiation,⁽²⁾ and 3) the reversible Raman intensity increase at 490 cm⁻¹ observed here. It should be emphasized, however, that the type 1 and 2 variations differ markedly from the type 3 variation--annealing is required to produce reversibility for types 1 and 2.

In previous Raman work, (2-4) lines near 490 and 604 cm⁻¹ were assigned to defects of the type $-Si - 0 \cdots Si -$, where the dots refer to a broken bond. However, in view of the EPR inactivity of ordinary bulk fused silica, (17) it is more appropriate to think of the defect as a stretched bond, or related to the effects of a stretched bond. Such a stretched bond would have a smaller force constant, <u>i.e.</u>, would be dynamically weakened, but would certainly not be broken from an energetic point of view, that is, it would not be a point defect in the usual sense. Such a "defect" could be considered as a Si-0 bond associated with a small (<u>e.g.</u>, less than 120°) bridging bond angle, and consequently with a large (<u>e.g.</u>, greater than 1.68 A) Si-0 bond length. (18)

In regard to a decreased force constant, no significant frequency shifts were observed in this work, and in previous Raman work, (4) for the defect lines at 490 and 604 cm.⁻¹ Also the shifts reported for the defect lines by Bates et al.⁽²⁾ are 2% or less. Thus, the 490 and 604 cm^{-1} lines probably refer to vibrational modes affected by, but not directly related to, the Si---0 elongation involved. Further, the 490 and 604 cm^{-1} Raman lines are unusually sharp for glasses. Thus, it is not unreasonable to relate these lines to local modes decoupled from the silica network by virtue of a stretched Si---- 0 bond, e.g., modes of the 0_3 Si or $0Si0_3$ units and/or of the 0_3 Si--0Si0_3 grouping, in which one intervening and elongated Si---- 0 bond Because the concentration of stretched Si--O bonds may be only about $6 \times 10^{19}/\text{cm}$, 3 (4,19) or about 0.1%, a significant lowering of the stretching frequency at 1060 cm^{-1} would not be expected. that is. most of the Si--- 0 vibrations correspond to the main glass structure.

In previous Raman studies of fused silica, it was estimated that a small fraction, roughly $6 \times 10^{19}/\text{cm}^{3}$ ⁽⁴⁾ of defects, for example, of highly elongated Si—0 bonds might exist. This highenergy fraction would be "frozen" into the thermodynamically unstable structure that is produced by rapid quenching. Because such elongated bonds would constitute high-energy sites, they would probably react preferentially with water to form adjacent Si—0H groups.⁽¹³⁾ Further, high tensile stress might also increase the fraction of

(12)

elongated Si—0 bonds. Or, high tensile stress could alter structures immediately associated with the elongated bonds, <u>i.e.</u>, the effects of temperature rise and of tensile stress could be very different mechanistically. At any rate, the defects envisioned here are topological network defects associated with elongated high-energy Si—0 bonds whose concentrations may be changed by changes in T_F , or alternatively through preferential chemical reaction with H_00 , (3,4) GeO₂ or B_2O_3 , (3) etc.

It should also be mentioned that when uniaxial stress is applied to fused silica, changes such as the intensification of Raman shoulders at 350-375 cm⁻¹ and at 115 \pm 5 cm⁻¹ occur, along with the intensity increases at 490 cm.⁻¹ Apparently, the main silica network suffers reversible distortions, as well as the reversible bond elongations related to the defects. The intensifications of Raman shoulders observed here are significant, and do not appear to have been observed previously.

The magnitude of the intensity changes observed in the tensile stress experiments can be shown to be surprisingly large compared to the energy imparted to the fused silica optical fiber by virtue of the work done in stretching it. Our measurements indicate that a 7 kg weight, when suspended from a fiber 200 µm in diameter (tensile stress, 2.19 GPa) and 447 cm long, stretches the fiber about 12.7 cm. The work done is thus 0.41 kcal/mole SiO_2 , or 14.8 cal/cm³ SiO_2 . This work amounts to only 0.2% of the standard heat of formation of SiO_2 glass at 25°C, ($\Delta H_f^o = 202.5$ kcal/mole $\operatorname{SiO}_2^{(20)}$), and thus it is 10^{-3} times smaller than the Si—0 bond energy. (The Si—0 bond energy may be crudely approximated by dividing the ΔH_f^o by 4, because

(13)

there are 4 Si—0 bonds per stoichiometric SiO_2 .) However, if the defects involve stretched, rather than broken bonds, and the energy due to stretching goes disproportionately into the defect sites, the effect would be non-negligible. In this regard, the following calculation, although forced, is instructive.

Consider that the defect concentration is roughly 6 x $10^{19}/cm$, 3 (4) and that this concentration increases 60-70 % due to tensile stress, as might be inferred from the increase in the I_{490}/I_{440} ratio (Table II). Then the change in the defect concentration would be about 4 x 10^{19} /cm.³ Because there are 4 Si---0 bonds per stoichiometric SiO2, the total concentration of Si--- 0 bonds is about 9×10^{22} /cm,³ which means that the fraction changed by stretching would be 4×10 .⁻⁴ The product of the work, about 15 cal/cm³, times 4×10^{-4} is 0.01 cal/cm,³ which would be the energy imparted by equipartition to the new defects contained in 1 cm.³ Because this amount of energy seems negligibly small, and the Raman intensity change at 490 $\rm cm^{-1}$ is visually obvious, a disporportionate amount of the work of stretching might go into creating new defects. The remaining energy, which certainly is most of the work of stretching, would go into the main silica network, as evidenced by shape changes near 350-375 cm⁻¹ and 115 cm.⁻¹ Alternatively, because T_F is constant during stretching, a small fraction of the work of stretching could go into stretching the existing temperature-induced defects even farther, as opposed to creating new defects. This additional stretching could produce structural changes which result in matrix element effects leading to increased intensity at 490 cm.⁻¹ Unfortunately, this alternative

(14)

process, although almost certainly more realistic than one involving production of additional new defects, is virtually impossible to approximate energetically at this time.

Finally, with regard to mechanistic differences between fictive temperature and uniaxial tensile stress, the reversible nature of the present experiments should be strongly emphasized. For example, annealing is required to remove the neutron-induced "defects" which give rise to greatly increased Raman intensity at 604 cm.^{-1 (2)} Whereas, with application of tensile stress, the 20-30 minutes, ⁽¹⁶⁾ Raman spectral changes are reversible (although the actual relaxation times, which are probably very short compared to 20 minutes, have not been measured. (16)) Further, the present relaxational behavior may also be contrasted to the situation in which qualitatively similar Raman intensity changes in the 490 and 604 cm^{-1} defect components resulted for samples having T_{p} values of 1400°C, after annealing for 200 hr at 1100°C.⁽⁴⁾ Hence, the presently observed reversibility is in accord with a bond stretching mechanism, whereas bond breaking or the production of new defects would probably be irreversible at room temperature.

(15)

SUMMARY AND CONCLUSIONS

The results of a new type of experiment are presented in which high tensile stress is applied to a long fused silica optical fiber while simultaneously obtaining its Raman spectrum by forward scattering. Intensification of a sharp Raman peak near 490 cm⁻¹ was observed with increasing tensile stress, and the reversible nature of the intensification contrasts with previous Raman observations in which annealing was required to produce reversibility. The Raman intensification was interpreted in terms of a decoupled local mode resulting from a stretched Si---O defect site.

(16)

(17)

ACKNOWLEDGEMENTS

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NOTE ADDED IN PROOF

Raman experiments have recently been conducted of the rate of increase of the OH-stretching peak intensity at 3700 cm,⁻¹ relative to the 800 cm⁻¹ silica peak intensity, for a silicone rubber clad fused silica optical fiber, with and without tensile stress. To stresses of 1.56 GPa, no significant increase in the rate of the OH-stretching intensity, above the slow rise characteristic of the water uptake of the unstressed fiber, could be detected. Thus, the reversible increase in the 490 cm⁻¹ peak intensity observed in this work, and the lack of a corresponding effect on the rate of water uptake, contrasts with the decreased intensity observed at 490 and 604 cm^{-1} when the OH content increases at constant T_{p} .⁽⁴⁾ It would appear, therefore, that no additional chemically active sites result when increased tensile stress is applied to a fused silica fiber. On the contrary, it now seems that the 490 cm^{-1} intensification is a matrix element effect associated with a structural change in existing defects. The Raman experiments involving the rate of water uptake will be described more fully elsewhere.

(18)

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(19)

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CAPTION

Fig. 1. Forward Raman scattering from fused silica optical fiber stressed to 3.34 GPa (upper), and unstressed (lower). Spectra in the inset were obtained in the sequence unstressed, U; stressed to 2.19 GPa, S; and, relaxed, R. Note that the inset spectra have been moved to the left--their position does not correspond to the cm^{-1} values below them. Baselines A and B are shown by dashes.



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Fig. 2. Schematic illustration of method used to obtain forward Raman spectra from an optical fiber while applying tensile stress.



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Table I. Raman peak height ratios (I refers to peak height) for the 60, 440, and 800 cm^{-1} peaks from fused silica for tensile stresses to 2.19 GPa.

TABLE I

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Stress	1 ₆₀ /1 ₄₄₀	I ₈₀₀ /I ₄₄₀	I ₈₀₀ /I ₆₀
O GPa	0.68	0.17	0.25
0.31	0.69	0.17	0.24
0.62	0,69	0.17	0.25
0.94	0.71	0.17	0.24
1.25	0.72	0.17	0.24
l.56	0.71	0.18	0.25
1.87	0.67	0.17	0,26
2.19	0.71	0.18	0.25

CAPTION

Table II. Ratios of integrated Raman intensities and peak heights for the 440, 490, and 604 cm⁻¹ peaks from fused silica. I_{490} and I_{604} refer to integrated component intensities above baseline B, Fig. 1. I_T is the total integrated intensity above baseline A, minus the 490 and 604 cm⁻¹ component areas above baseline B. I_{440} is the peak height above baseline A at 440 cm.⁻¹ TABLE II

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Stress	I ₄₉₀ /I _T	I ₆₀₄ /I _T	I ₄₉₀ /I ₄₄₀	I ₆₀₄ /I ₄₄₀
O GPa	0.011	0.013	0.0009	0.0011
0.31	0.011	0.015	0.0009	0.0012
0.62	0.012	0.014	0.0010	0.0011
0.94	0.014	0.013	0.0011	0.0011
1.25	0.016	0.013	0.0013	0.0011
1.56	0.016	0.015	0.0013	0.0012
1.87	0.016	0.013	0.0013	0.0011
2.19	0.017	0.013	0.0015	0.0011

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